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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventive Application of

SALIL D. PATEL, SUNIL MAULIK, and JERRY BROSAN

December 11, 2001

Serial No. : 09/981,647

Filed : October 15, 2001

For : COMPUTER-BASED EDUCATION SYSTEM FOR SCIENTIFIC
PROCEDURES WITH PRODUCT PROCUREMENT CAPABILITYCommissioner for Patents
Washington, D.C. 20231

Sir:

INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. §§ 1.56, 1.97 and 1.98

Pursuant to applicants' duty of disclosure required under 37 C.F.R. § 1.56, applicants are submitting the enclosed, completed PTO forms 1449 with copies of each reference as required by 37 C.F.R. §§ 1.97 and 1.98. The listing of any reference or the submission of a copy of any reference shall not be deemed as an admission that the listed or submitted reference is prior art for this application.

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on December 11, 2001.

Shannon Verboort

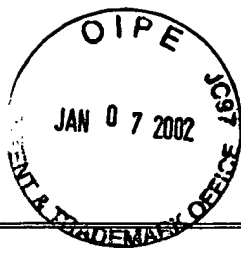


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PATENT TRADEMARK OFFICE

Respectfully submitted,

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SHEET 1 OF 1

FORM PTO-1449 INFORMATION DISCLOSURE CITATION IN AN APPLICATION		DOCKET NUMBER GMS 303		APPLICATION NUMBER 09/981,647		
		APPLICANT Salil D. Patel, Sunil Maulik and Jerry Brosnan				
		FILING DATE October 15, 2001		GROUP ART UNIT 2173		
U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.
	5,395,243	3/7/95	Lubin et al.			
	6,029,043	2/22/00	Ho et al.			
	6,032,141	2/29/00	O'Connor et al.			
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO
OTHER DOCUMENTS						
EXAMINER			DATE CONSIDERED			

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